

PROCEEDINGS OF SPIE

Pacific-Rim Laser Damage 2019

Optical Materials for High-Power Lasers

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Editors

19–22 May 2019
Qingdao, China

Sponsored by
SPIE
SIOM—Shanghai Institute of Optics and Fine Mechanics (China)

Organized by
Chinese Laser Press
Qingdao University (China)
Shandong Society for Optical Engineering (China)

Cooperating Organizations
Chinese Academy of Sciences
Qingdao Physical Society (China)
The National Natural Science Foundation of China

Published by
SPIE

Volume 11063

Proceedings of SPIE 0277-786X, V. 11063

SPIE is an international society advancing an interdisciplinary approach to the science and application of light.

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Please use the following format to cite material from these proceedings:

Author(s), "Title of Paper," in *Pacific Rim Laser Damage 2019: Optical Materials for High-Power Lasers*, edited by Jianda Shao, Takahisa Jitsuno, Wolfgang Rudolph, Proceedings of SPIE Vol. 11063 (SPIE, Bellingham, WA, 2019) Seven-digit Article CID Number.

ISSN: 0277-786X
ISSN: 1996-756X (electronic)

ISBN: 9781510628168
ISBN: 9781510628175 (electronic)

Published by

SPIE

P.O. Box 10, Bellingham, Washington 98227-0010 USA
Telephone +1 360 676 3290 (Pacific Time)- Fax +1 360 647 1445

SPIE.org

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Contents

vii *Authors*
xi *Conference Committee*

SESSION 1 HIGH LASER DAMAGE RESISTANT COATINGS

11063 02 **Investigation on damage process of indium tin oxide film induced by 1064nm quasi-CW laser**
[11063-67]

SESSION 2 HIGH POWER LASER DAMAGE, UV THROUGH IR I

11063 03 **The fatigue effect of femtosecond laser-induced damage in high-reflective coatings at low repetition rate** [11063-35]

11063 04 **Laser conditioning mechanism in DKDP crystals analyzed by fluorescence and stimulated Raman scattering technique** [11063-62]

SESSION 3 HIGH POWER LASER DAMAGE, UV THROUGH IR II

11063 05 **Investigation of laser induced air breakdown thresholds at 1064, 532, 355, 266 and 248nm**
[11063-19]

SESSION 4 CHARACTERIZATION TECHNIQUES AND MEASUREMENT PROTOCOLS I

11063 06 **Molecular simulation and ablation property on the laser-induced metal surface** [11063-42]

SESSION 6 NONLINEAR LASER CRYSTALS

11063 07 **Laser-induced damage of nonlinear crystals in ultrafast, high-repetition-rate, mid-infrared optical parametric amplifiers pumped at 1 μm (Invited Paper)** [11063-58]

11063 08 **Optimizing the flow conditions of the horizontally oriented DKDP crystal by adding a stirring paddle** [11063-47]

SESSION 8 CHARACTERIZATION TECHNIQUES AND MEASUREMENT PROTOCOLS II

- 11063 09 **Laser-induced damage of high power systems: phenomenology and mechanisms (Invited Paper)** [11063-15]
- 11063 0A **Analysis of optical damage in the final optics assembly induced by transport mirror defects** [11063-22]
- 11063 0B **Removal of particle contaminations on sol-gel coated fused silica surface by laser cleaning** [11063-31]

SESSION 10 CHARACTERIZATION TECHNIQUES AND MEASUREMENT PROTOCOLS III

- 11063 0C **Structural defects in ultra-low laser absorption fused silica** [11063-49]

POSTER SESSION

- 11063 0D **Research on the single and multiple pulse laser damage performance of UV anti-reflection coatings** [11063-38]
- 11063 0E **Polarization dependence of propagation features modeling for optical micro/nano fiber in circularly bent shape** [11063-18]
- 11063 0F **Design, fabrication and laser damage comparisons of low-dispersive mirrors** [11063-69]
- 11063 0G **Research on precision space linear rolling guide dynamics** [11063-21]
- 11063 0H **A focusing mechanism based on flexible hinges for space telescope** [11063-32]
- 11063 0I **Study on damage of CaF₂ windows irradiated by 248nm ultraviolet excimer laser** [11063-12]
- 11063 0J **Study on thermal effect and thermal stress effect of multilayer thin films induced by pulsed laser** [11063-24]
- 11063 0K **Transient dynamic behavior during nanosecond laser-induced damage initiated by surface defects on KDP crystals with simulation and experimental method** [11063-59]
- 11063 0L **A new method for air quality observation based on ultraviolet laser** [11063-51]
- 11063 0M **Analysis of stray light reflected from multi-beam laser focusing surface** [11063-55]
- 11063 0N **Assessment of high-purity quartz glass by laser induced fluorescence technique** [11063-46]
- 11063 0O **High power all-fiber laser with switchable pulsed and continuous operation modes for wind lidar** [11063-43]

- 11063 OP **Laser damage and damage performance caused by near-field of final optics assemblies for high power laser system** [11063-54]
- 11063 OQ **Laser damage on large aperture triple frequency crystal optics in high power laser system** [11063-57]
- 11063 OR **Numerical investigation of growth model for laser-induced damage in optics under high power laser irradiation** [11063-40]
- 11063 OS **Research on high precision combined processing technology of meter-level optical glass guideway** [11063-13]
- 11063 OT **Study on 532nm and CO₂ laser processing of fused silica glass** [11063-64]
- 11063 OU **Thermal deformation measurement of Al₂O₃ ceramic substrate based on radial basis function** [11063-16]
- 11063 OV **Design and fabrication all-dielectric broadband reflection phase shifting mirror at near-infrared wavelengths for high intensity lasers** [11063-30]
- 11063 OW **Equivalent explosion simulation model for studying the laser-induced damage process of KDP crystal** [11063-52]
- 11063 OX **Experimentation on ablation of polymer plastics by CW laser for high voltage transmission lines** [11063-8]
- 11063 OY **Fast measurement technique for obtaining the low damage threshold defects in a large aperture fused silica glass** [11063-28]
- 11063 OZ **Investigation of the high repetition rate picosecond laser induced damage properties of dielectric reflective optical coatings** [11063-45]
- 11063 10 **Laser damage characteristics of the YAG ceramics** [11063-1]
- 11063 11 **Mitigation of laser induced damage on dielectric mirrors in a robust way** [11063-72]
- 11063 12 **Morphology evolution of doped phosphate glass in ion beam figuring** [11063-66]
- 11063 13 **Preliminary application research of regression analysis in camouflage color matching** [11063-17]
- 11063 14 **Removal of defect bound exciton in aged monolayer WS₂ by laser processing** [11063-25]
- 11063 15 **Research on autonomous landing of UAV based on vision sequence image** [11063-10]
- 11063 16 **Study on IR laser smoothing of ground surface on fused silica** [11063-48]
- 11063 17 **Designing of converging stray light focal spot absorber in high power laser system** [11063-34]

- 11063 18 **Research status and analysis of fifth-harmonic-generation for $\sim 1\mu\text{m}$ laser** [11063-56]
- 11063 19 **Simulation of heat distribution and thermal damage patterns of pulse laser for uterus using finite element analysis** [11063-9]
- 11063 1A **The study on damage threshold of CCD's black and white screen** [11063-33]
- 11063 1B **Ablation characteristics of aluminum alloy and stainless steel induced by picosecond laser pulses** [11063-44]
- 11063 1C **Third-order nonlinear optical response of enzothiazole derivative doped Polymethyl methacrylate $\text{C}_{18}\text{H}_{15}\text{N}_3\text{SFe}$** [11063-26]
- 11063 1D **Study on magnetic properties of oriented silicon steel scribed by ultrafast laser** [11063-53]
- 11063 1E **Study on optical constants of coatings at different temperatures** [11063-60]
- 11063 1F **Study on surface roughness change of modified silicon carbide in ion beam polishing** [11063-63]
- 11063 1G **Influence of laser output parameters on film damage threshold** [11063-27]
- 11063 1H **Laser modulation simulation of micro-crack morphology evolution during chemical etching** [11063-65]
- 11063 1I **A theory model on multi-shot laser-induced damage of multilayer mirrors in nanosecond** [11063-20]